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		Application Number	10/646,316
		Filing Date	08/22/2003
		First Named Inventor	Randall R. Clark
		Group Art Unit	1733
		Examiner Name	Jeff H. Aftergut
Sheet	1	of	1
		Attorney Docket Number	
		091-0189	

U.S. PATENT DOCUMENTS

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Examiner Signature		Date Considered	3 / 30 / 06
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